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Charge Transport through Molecules Supported by Flexible Electrodes

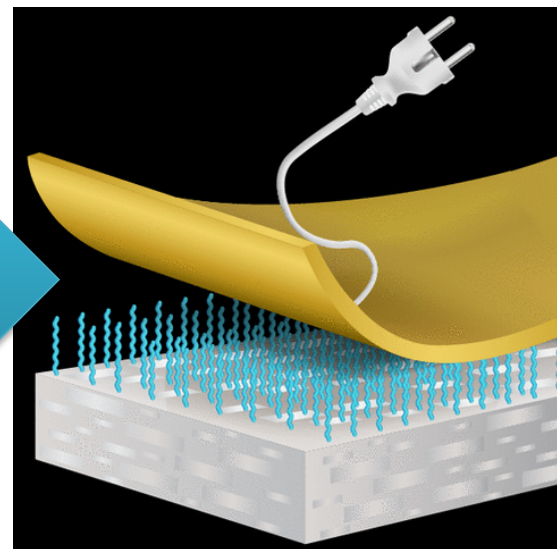
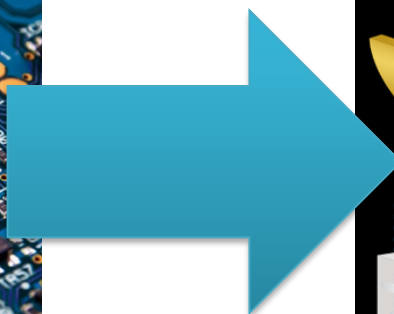
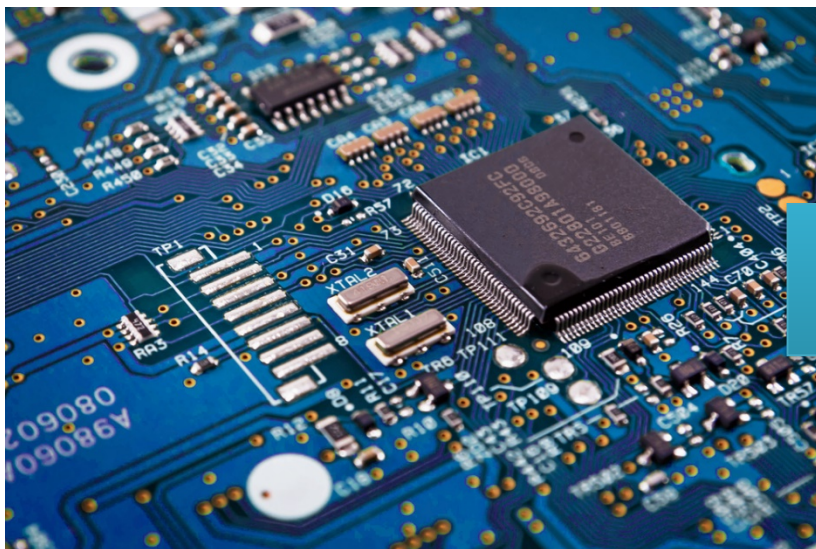
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Whitesides Research Group

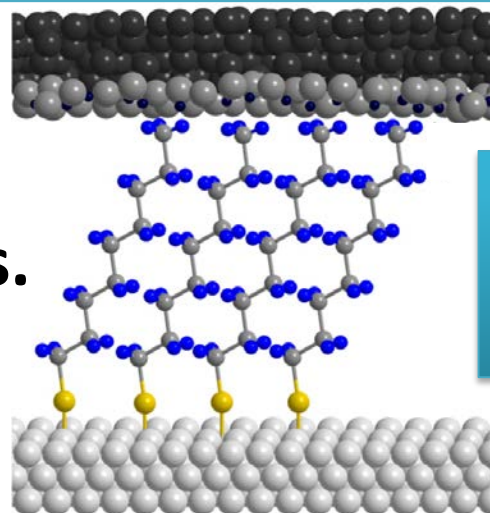
Molecular electronics (MoEI)



- Non-equilibrium
state

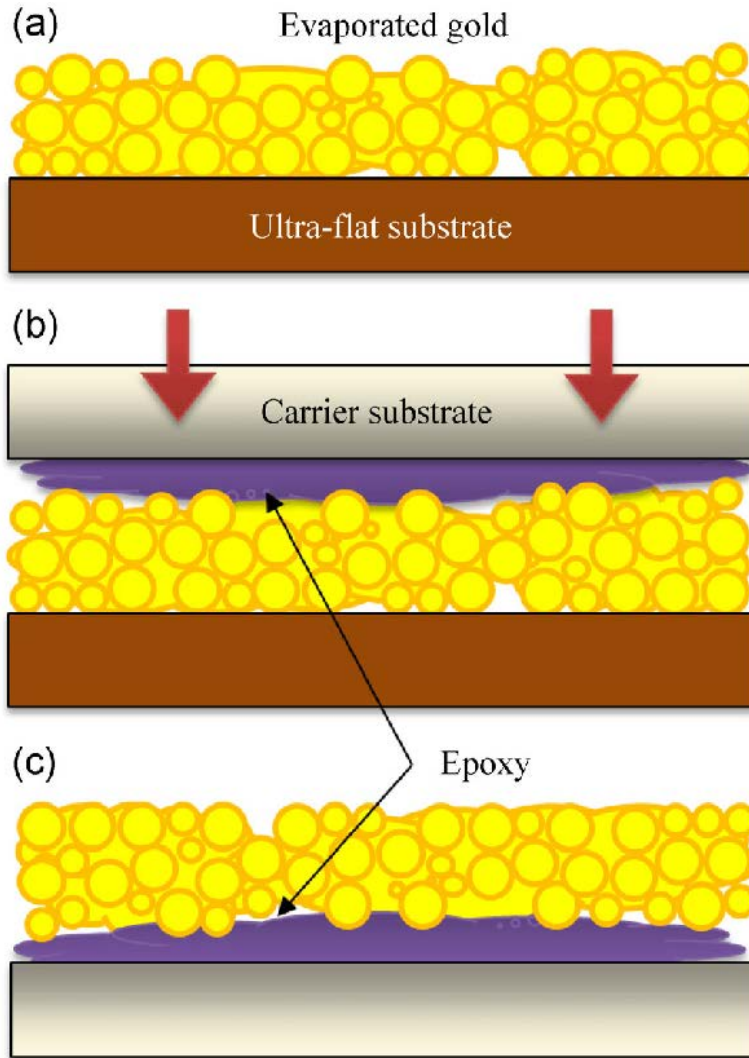


vs.



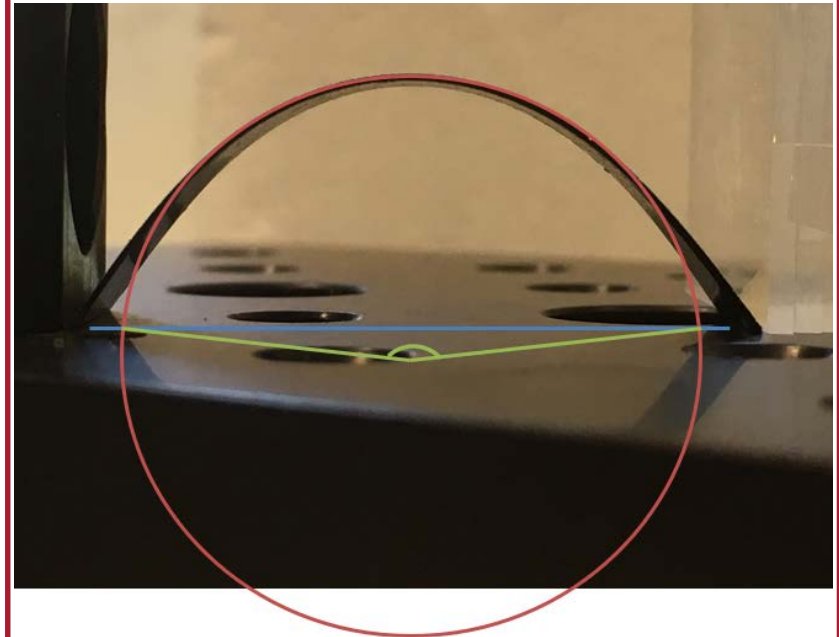
- Intrinsic stability
- Reproducibility
- Structural
information

Bottom-electrode



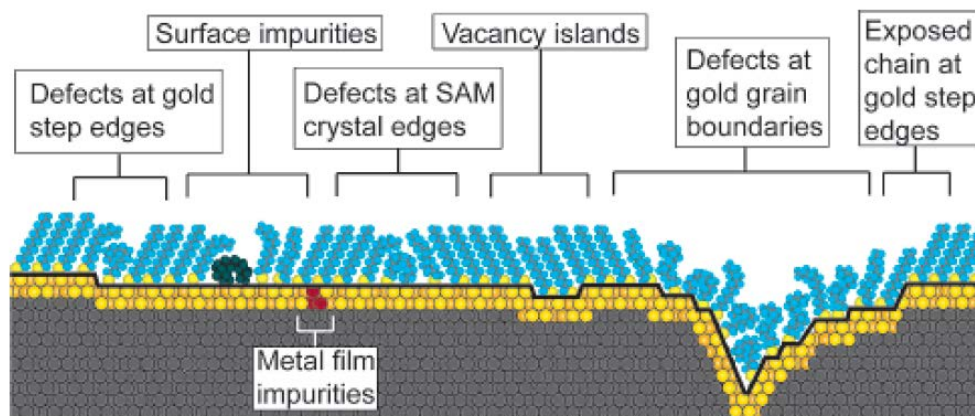
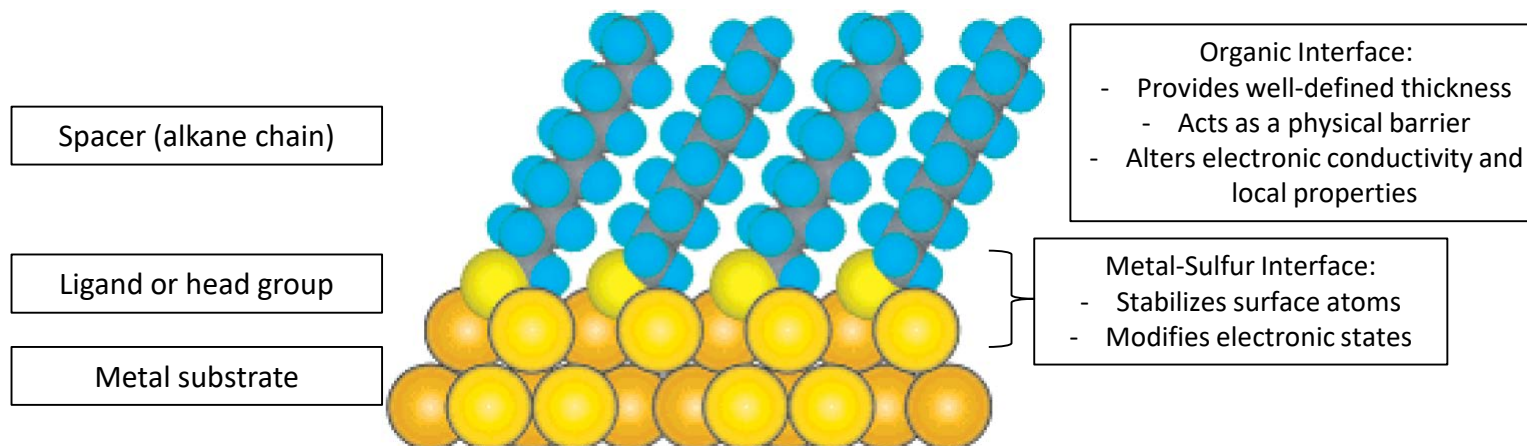
We used a silicon wafer as the ultra-flat substrate and polyamide (polymer) as the carrier substrate.

How is the bending angle of the bottom-electrode measured?



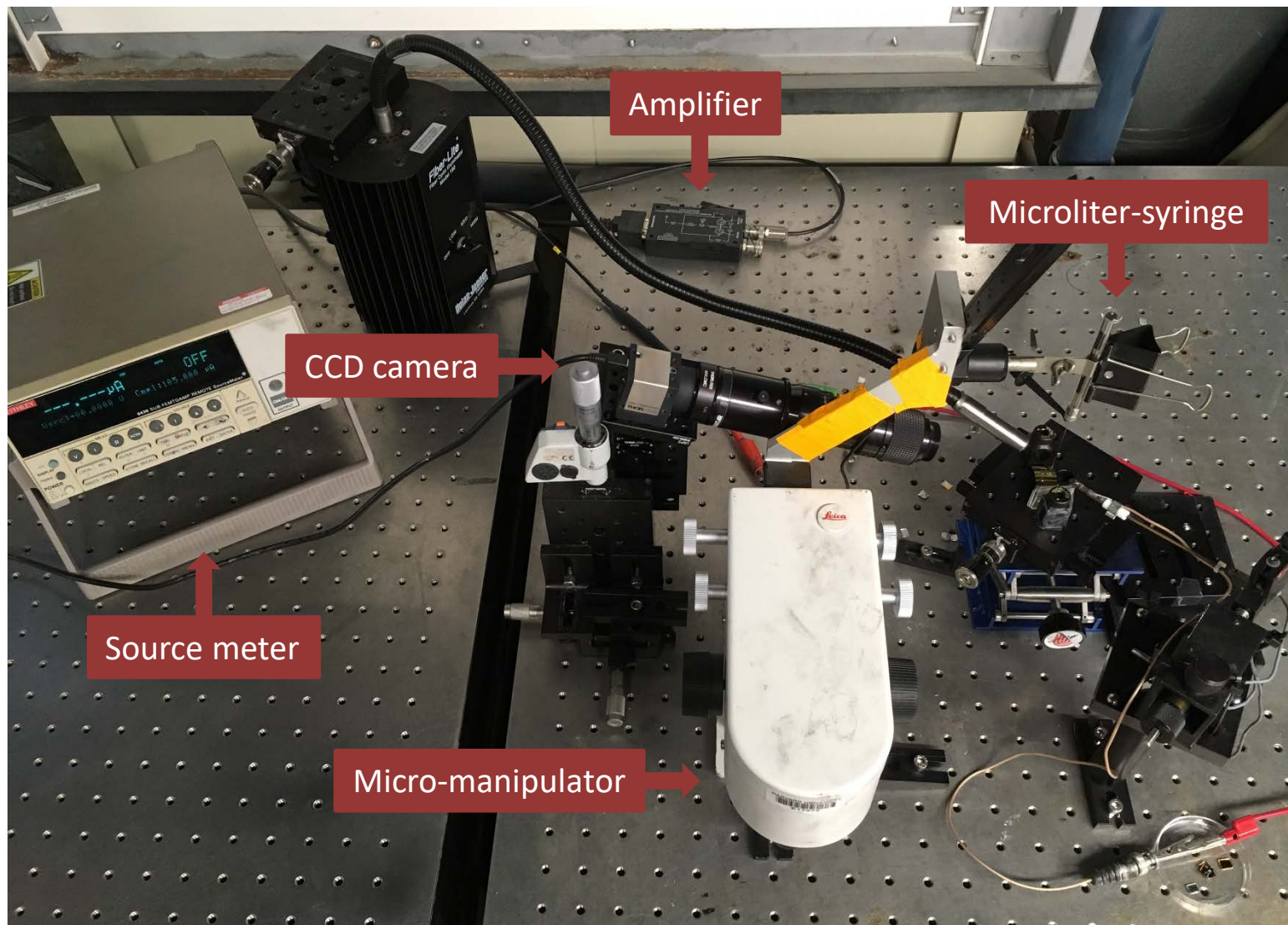
- ❖ M. E. Celestin, S. Krishnan, S. Bhansali, E. Stefanakos and D.Y. Goswami, *Nano Research* **7**, 5 (2014)

Self-assembled monolayer (SAM)





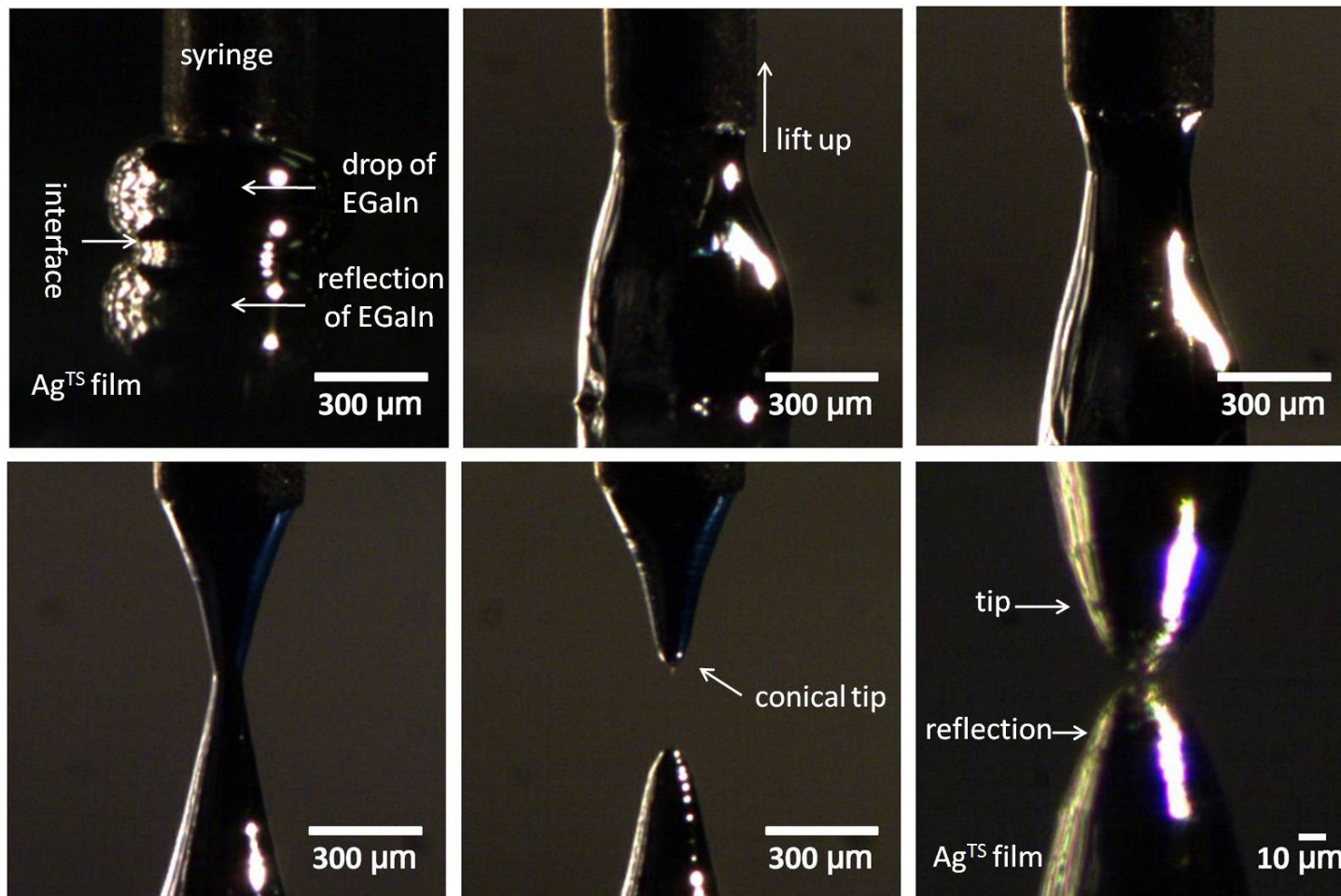
Home-built EGain setup





Preparation of the cone-shaped EGaIn top-contact

EGaIn: eutectic alloy of gallium (75.5%) and indium (24.5%), mp = 15.7°C

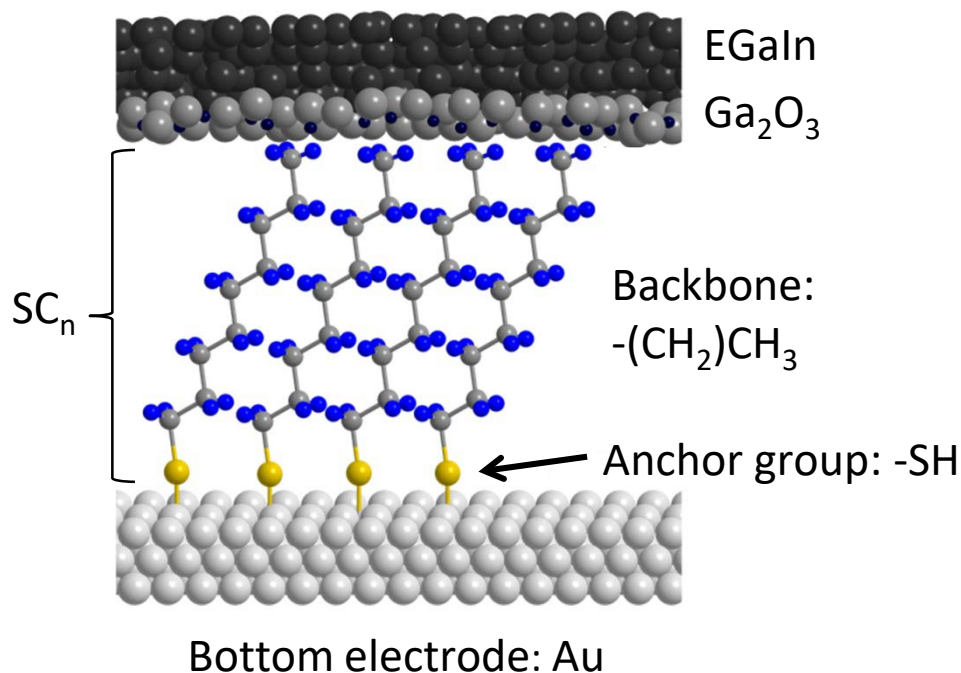


SAM based junctions with liquid metal



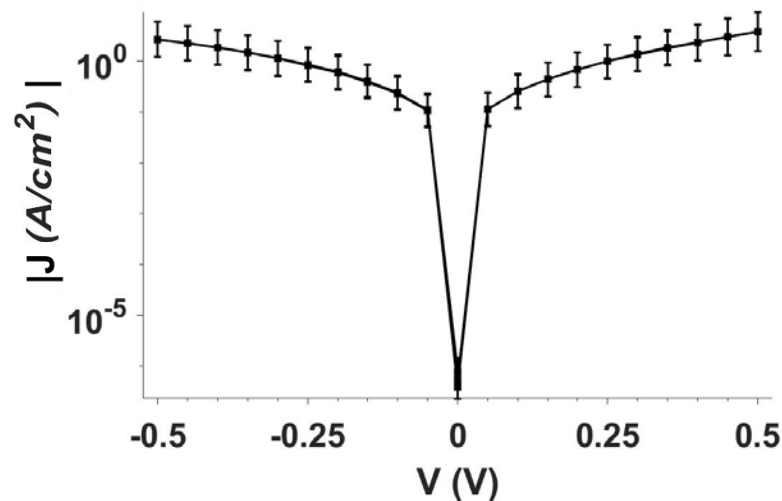
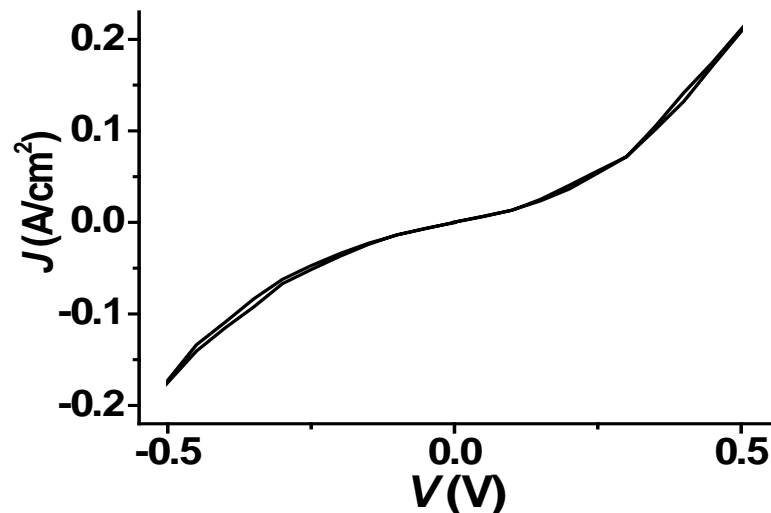
SC_n SAM
as standard platform
(SC_n: n-alkanethiol)

Top-electrode: EGaIn



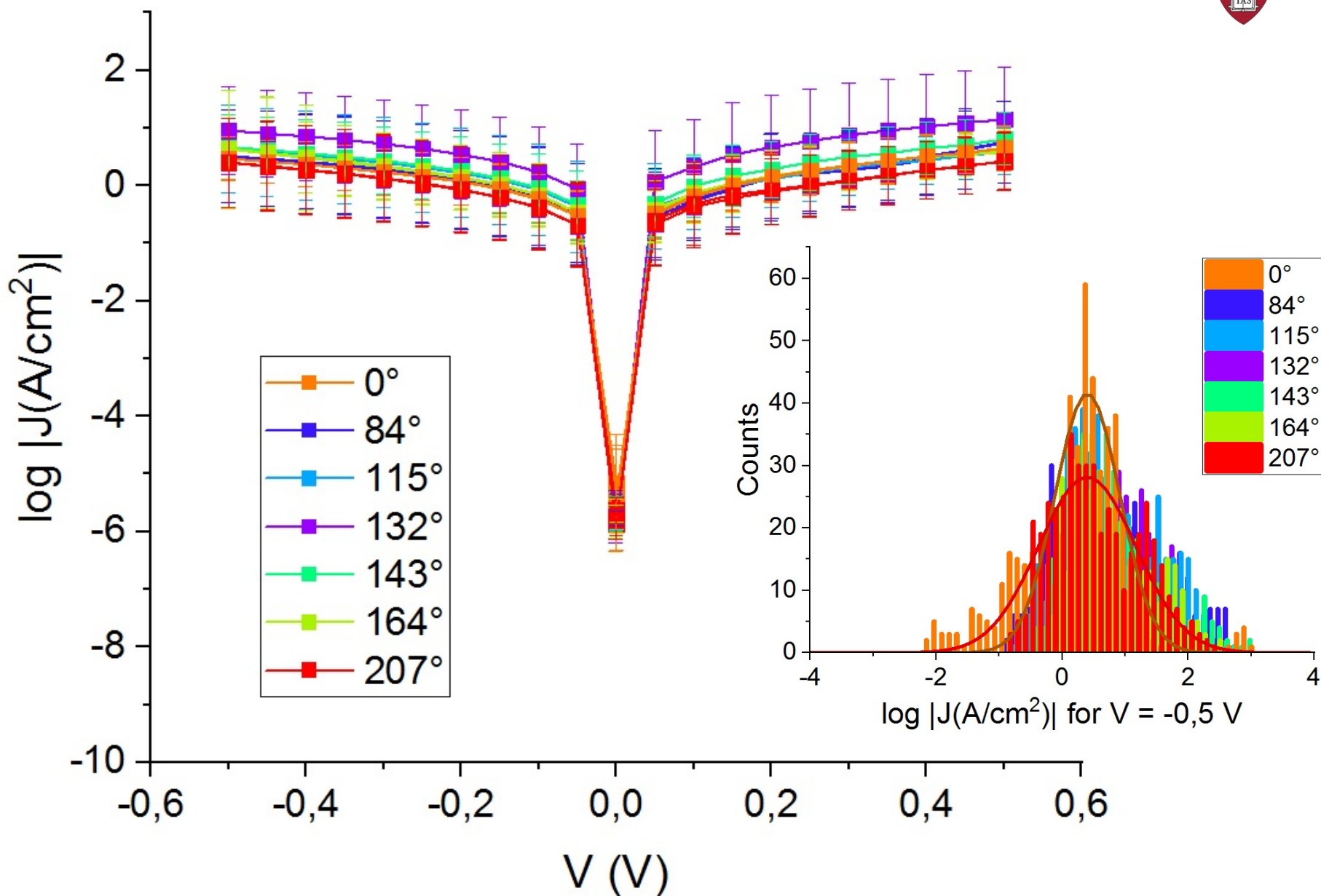
Typical $J(V)$ curve

J : Current density
(current divided by contact area)



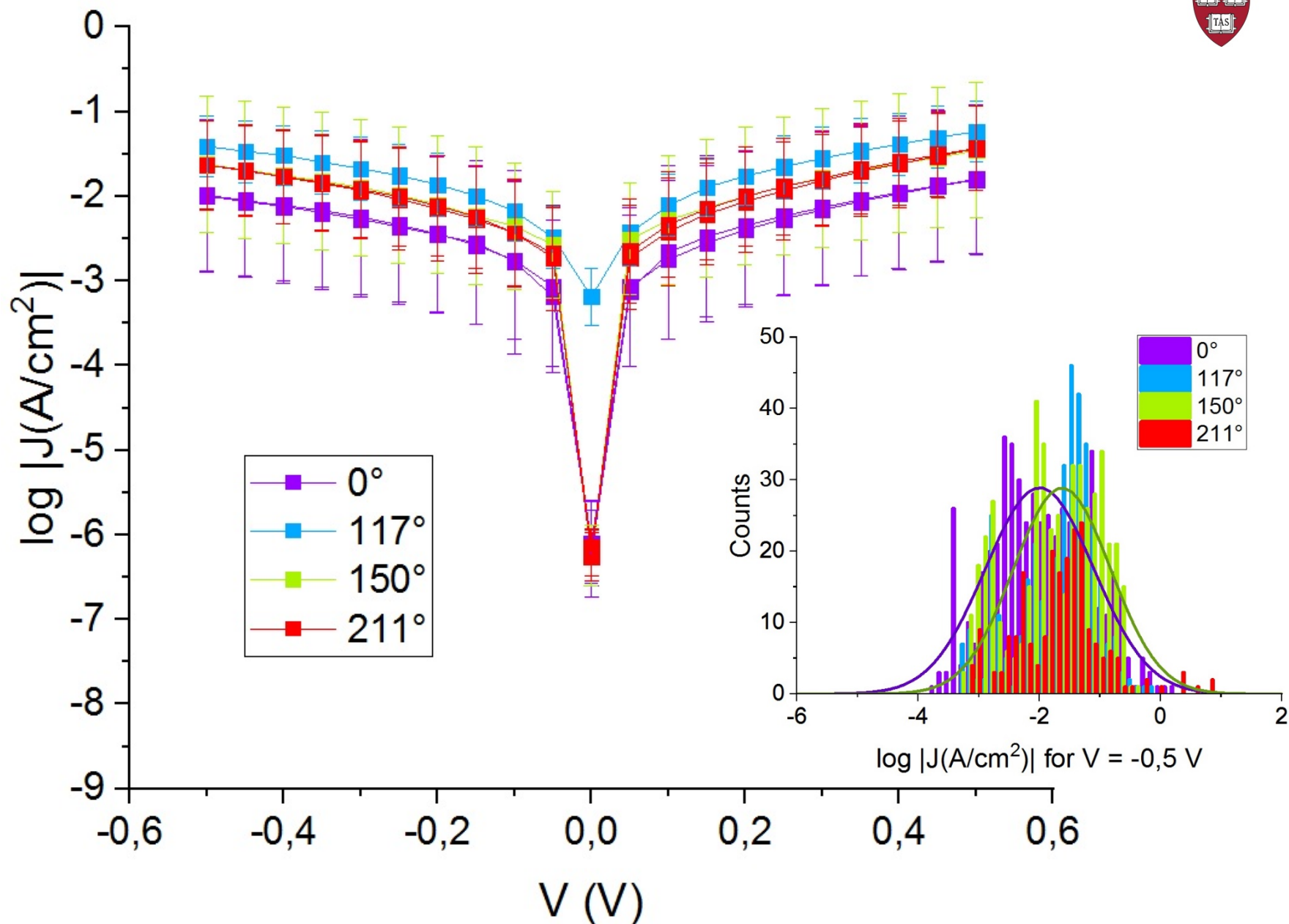


J(V) measurements of junctions with SC₁₀ SAMs



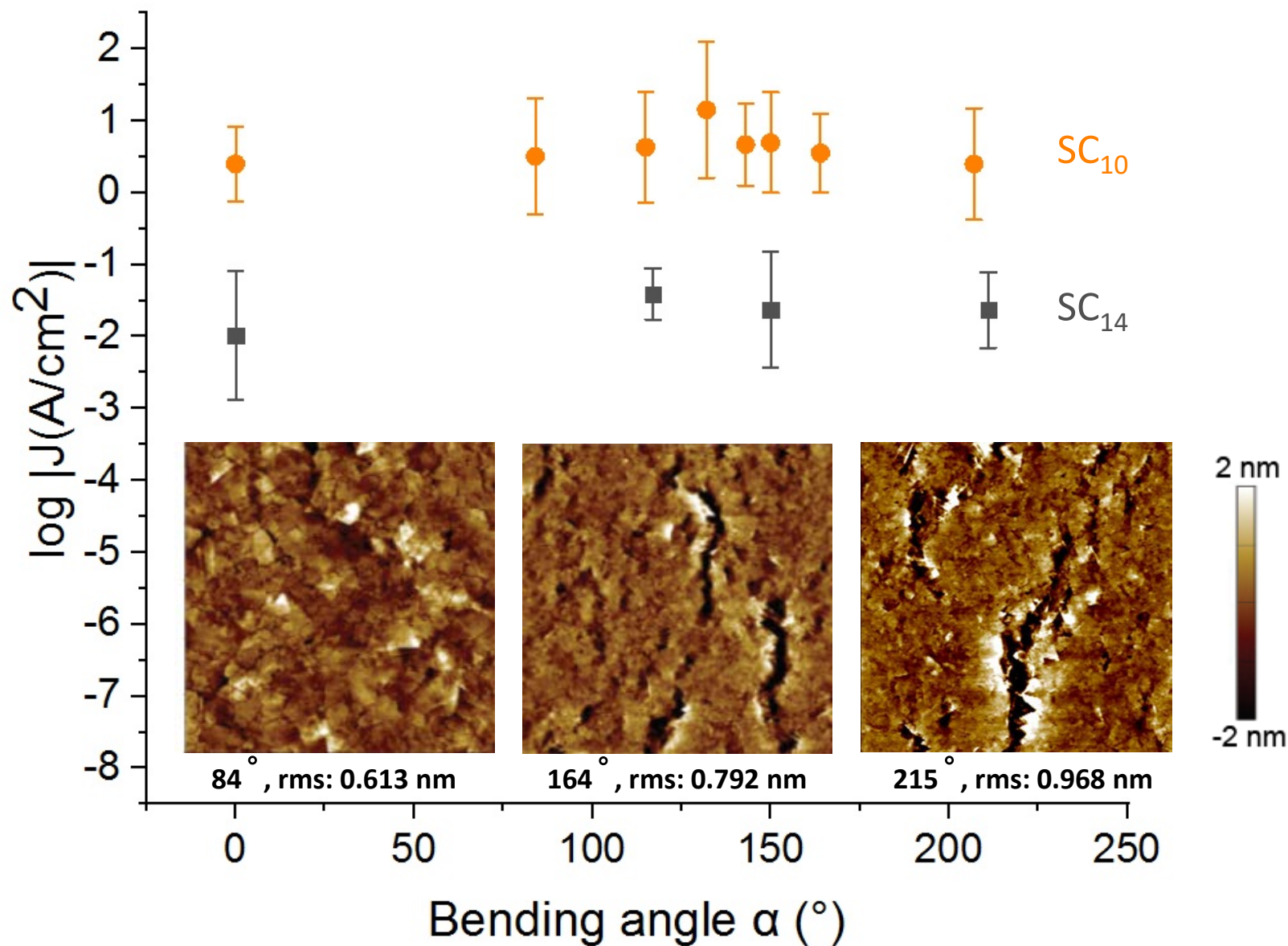


J(V) measurements of junctions with SC₁₄ SAMs





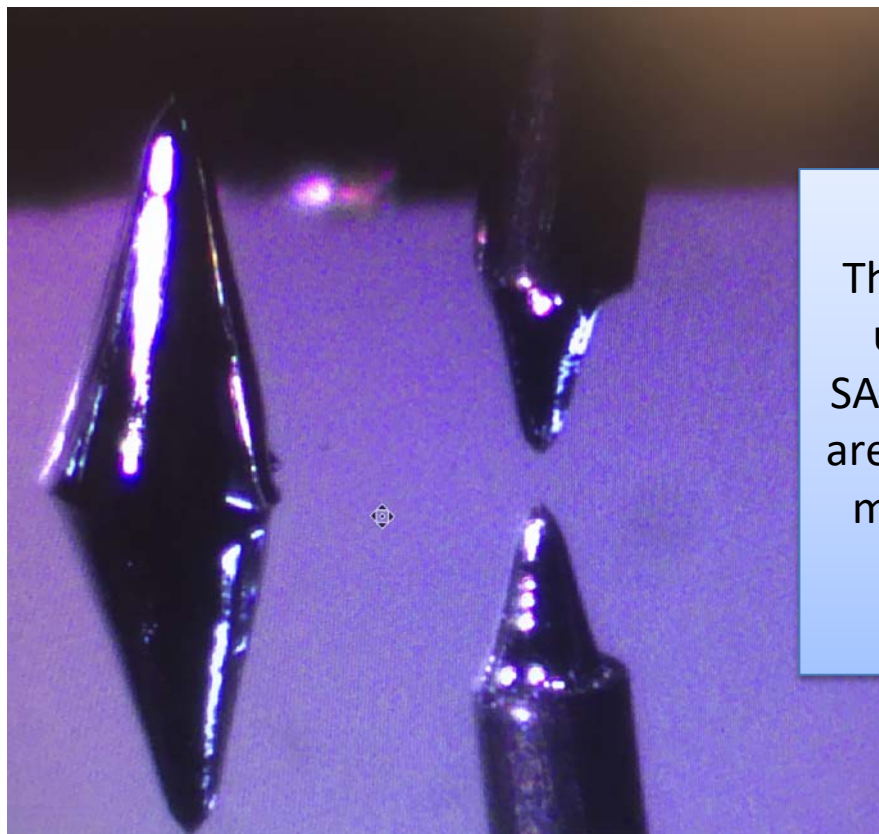
$J(V, \alpha)$ measurements for $V = -0,5$ V





Conclusions and future experiments

The **SAM-based junctions built are robust.** The tunneling current doesn't change even when large deep valleys form in the bottom-electrode for bending angles $\alpha > 150^\circ$ due to tensile stress.



The experiment should be repeated using junctions with SC_{18} and SC_6 SAMs to determine if these junctions are robust when they comprise SAMs made up of other molecules of the series of n-alkanethiols.

Acknowledgements



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